Nonadiabatic chemical-to-electrical energy conversion in heterojunction nanostructures

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Nonadiabatic energy dissipation by electron subsystem of nanostructured solids unveil interesting opportunities for the solid-state energy conversion and sensor applications. We found that planar Pt/GaP and Pd/GaP Schottky structures with nanometer thickness metallization demonstrates a nonadiabatic channel for the conversion into electricity the energy of a catalytic hydrogen-to-water oxidation process on the metal layer surface. The observed above thermal current greatly complements the usual thermionic emission current and its magnitude is linearly proportional to the rate of formation and desorption of product water molecules from the nanostructure surface. The possibilities of utilizing the nonadiabatic functionality in chemical-to-electrical energy conversion devices are discussed.

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I. INTRODUCTION

Many chemical processes on metal surfaces flow highly exothermally providing energies in the order of electron volts per reaction event.1,2 The successive processes of energy dissipation have until recently been interpreted within the thermal equilibrium settings implying a dominant role of the adiabatic energy exchange with the reactive adsorbate species and leading simply to heating of the metal surface. Meanwhile, more recent studies indicate that the chemical energy dissipation may also occur through direct excitation of the electronic system of the metal, i.e., in a thermodynamically nonadiabatic manner. For example, the publications3–5 show involvement of the nonadiabatic mechanism of energy dissipation during chemisorption of monatomic and polyatomic species, such as H, O, Xe, NO, and C2H4, to the ultrathin Ag films deposited on top of n- and p-type Si substrates and maintained at 135 K during the experiments. The metal-semiconductor heterostructures (Schottky diodes) Ag-Si were designed in a way allowing for the detection of the chemically induced electron excitations in the metal as a hot charge carriers current across the structure. These charge carriers are generated nonadiabatically in the exoergic chemical events on the surface and then emitted ballistically over the Schottky barrier and into the underlying semiconductor wafer. Chemically induced excitation of hot electron was also demonstrated in TiO2- and GaN-based Schottky nanodiodes at elevated sample temperatures, sufficient to initiate the heterogeneous catalytic processes of carbon monoxide oxidation.6–8

The present authors9,10 utilized Pd/6H-SiC Schottky heterostructures with nanometer thickness Pd films to demonstrate an effective chemically induced excitation of hot electrons at temperatures 350–800 K; the higher temperature regime allowed using the more complex reaction of catalytic hydrogen-to-water oxidation on the Pd film surface for the nonadiabatic electron excitation in the same metal film. Another group also used the catalytic hydrogen oxidation in a lower temperature range of 298–373 K to demonstrate hot-electron generation in Pt/TiO2 Schottky nanostructures.11

The study of nonadiabatic energy dissipative processes in the course of exoergic chemical reactions on metal surfaces provides interesting fundamental insights6,12,13 and also unveils exciting practical opportunities. One possibility being under consideration presently is the development of a distinct class of chemical-to-electrical energy conversion devices,9,14 which would utilize the nonadiabatic process to minimize heat losses and provide superior efficiency and energy density compared to the existing fuel cells. However, the relevant energy exchange processes arising form the reactive gas/metal surface interactions and leading to the chemically induced excitation of energetic electrons on metal surfaces without resorting to heat (as during photoexcitation of electrons in photovoltaic devices) are insufficiently understood at the present time.3,12,15 Besides, the quantum efficiency, number of electron generated per reaction event, of the systems studied by this time is relatively low being in the range of 10⁻⁴–10⁻³. Therefore, elucidation of basic properties this process for various metal-semiconductor heterostructures is very important for the development of nonadiabatic chemical-to-electrical energy conversion devices.

This paper provides a discussion of the direct conversion to electricity of chemical energy released in the hydrogen-to-water oxidation process on the surface of thin-film metal-semiconductor nanostructures with Schottky barriers using the wide band gap n-GaP (Eg=2.3 eV). For the comparison and study of the influence of Schottky contact physical properties on the energy conversion efficiency, the Pd and Pt thin films are considered. Temporal behavior of the generated current and its linearity to water desorption from the device surface are discussed. Individual contributions of the adiabatic and nonadiabatic channels of energy dissipation are estimated.

II. BASIC MECHANISMS

The basic concept of chemically induced charge-carriers detection utilized in the present work is schematically shown in Fig. 1. The thin-film metallization of the Schottky junction...
also serves as catalyst to the hydrogen oxidation in the lowpressure reactive oxyhydrogen mixture admitted to the film surface. Other reactive mixtures may alternatively be used, however, the $2\text{H}_2 + \text{O}_2 \rightarrow 2\text{H}_2\text{O}$ process employed here is very interesting for the sustainable energy perspectives. The energetic effects of surface recombination of hydrogen derived radicals are 1.17 eV and 0.91 eV for the $\text{H} + \text{OH} \rightarrow \text{H}_2\text{O}$ and $\text{OH} + \text{OH} \rightarrow \text{O} + \text{H}_2\text{O}$ processes, respectively.\textsuperscript{15,17} These two reactions comprise the last step in the catalytic oxidation of hydrogen to water on metal surfaces.\textsuperscript{15,17} The energy released in these processes may dissipate nonadiabatically via the direct excitation of energetic above thermal) electrons in the metal film. These electrons have energies and lifetimes sufficient to travel ballistically over the Schottky barrier and toward the semiconductor region. They further drift into the external circuit via the Ohmic back contact.

The metal-semiconductor heterojunction nanostructures with Schottky barriers were manufactured by depositing continuous 15 nm Pt and Pd layers onto a polished side of $n$-type GaP substrates of the size $18 \times 18 \times 0.5$ mm$^3$ and resistivity $0.03$ Ω cm, using e-beam evaporation in high vacuum ($< 10^{-7}$ Torr) at the rate 0.15 Å/s and substrate temperature 370 K. A partial masking of the substrate was applied to obtain square centered Schottky contacts of surface area 23 mm$^2$. Ohmic contacts were applied to the entire reverse nonpolished side of the substrates by thermal infusion of pure indium at 500 K. The fabricated structures had nonlinear diode-type voltage current characteristics. Thermionic emission analysis\textsuperscript{24} of the voltage-current curves was employed to determine the effective Schottky barrier height: 0.77 eV (Pd/GaP) and 0.74 eV (Pt/GaP). The chemically induced current was measured with a 10 kΩ input impedance nanovoltmeter.

Kinetics of the current recorded continuously during exposure of Pd/GaP and Pt/GaP samples at temperature 660 K to the oxyhydrogen stoichiometric mixture at pressure 0.2 Torr are shown in Fig. 2. A sharp peak of the current magnitude is observed at the time of mixture admission followed by an exponential decay toward the negative region and a successive steady growth toward a stationary value. The stationary regimes were typically achieved in 2–3 min after mixture admission. The magnitude of the stationary current increases with sample surface temperature reaching the values 1.8 μA and 0.84 μA, respectively, for the Pd/GaP and Pt/GaP structures at 660 K, see Fig. 3. Here, a decomposition of the current into the nonadiabatic (chemi) and adiabatic (thermo) components is also provided. Separation and measurement of the thermal component were accomplished by externally heating the given structures in vacuum, i.e., without mixture admission, to the...
FIG. 3. (Color online) Decomposition of the total current generated in Pd/GaP and Pt/GaP structures into the nonadiabatic (chemi) and adiabatic (thermo) components. The thermal current is owing to the usual thermionic emission over the Schottky barrier and to the thermoelectric Thompson effect in the semiconductor.

FIG. 4. (Color online) Chemicurrent as a function of water molecules desorption rate, \( r_w \). The chemicurrent magnitude can be approximated by a linear relationship of the type \( I_{ch} = e \eta r_w S \), where \( e \)—elementary charge, \( S \)—nanofilm surface area, and \( \eta \) is a dimensionless efficiency constant.

We conclude that planar Pd/GaP and Pt/GaP Schottky structures with nanometer thickness metallization can dem-
Demonstrate a strong nonadiabatic channel of surface chemical energy dissipation. The nonadiabatic component comprises up to 80% of the total chemically induced electric current arising from the catalytic oxidation of hydrogen to water on the nanostructure surface. The magnitude of the stationary current is determined by the rate of formation and desorption of product water molecules and well approximated by a linear dependence. The value of \( \eta = 0.1 \) found here is remarkably higher than typical quantum efficiencies of the chemically induced emission of electrons into vacuum being in the range of \( 10^{-6} - 10^{-8} \) electrons per chemical event on metal surface.\(^9\) This result provides grounds to seriously consider the chemically induced electron excitation in metals not only for studying gas-surface inelastic interactions, but also for energy conversion applications; these would combine physical functionality of the photovoltaic cells with usual advantages of the hydrogen-based power, such as cleanliness, mobility, and independence of external conditions. The energy efficiency estimated as ratio of the input chemical and output electric powers is not higher than a few percents for the samples studied here. Nonetheless, since the maximal theoretical efficiency of single junction barrier-layer structures as energy conversion devices is about 41%,\(^30\) a quest for more efficient metal-semiconductor combinations and device architectures will be well worthy of the effort. In particular, incorporation of a nanodot pattern to the device nanocathode could increase the catalyst surface area, as well as density of the adsorption centers, and thus increase the reaction turnover rate, leading to higher conversion efficiency and volumetric power density of these devices.

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